Paths of analysis*

Synthia

October 10, 2022

1 Analysis parameters

Analysis type: Automatic Retrosynthesis

Rules: none selected

Filters: Exclude Diastereoselecitve reactions, Tunnels, FGI, FGI with protec-

tions

Max. paths returned: 50

Max. iterations: 2000

Commercial:

1. Max. molecular weight - 1000 g/mol

2. Max. price - 1500 \$/g

Published:

- 1. Max. molecular weight 1000 g/mol
- 2. Popularity 5

My Stockroom:

1. Max. molecular weight - 1000 g/mol

Reaction scoring formula: TUNNEL_COEF*FGI_COEF*STEP*20+1000 000*(CONFLICT+NON SELECTIVITY+FILTERS+PROTECT)

Chemical scoring formula: SMALLER^ 3,SMALLER^ 1.5

Min. search width: 400

Max. reactions per product: 60

^{*}The results stated herein were generated using the proprietary platform owned and maintained by Grzybowski Scientific Inventions, Inc., a subsidiary of Merck KGaA, Darmstadt Germany. The results are provided on an as is basis, and shall be used solely in connection with the rights afforded in the license agreement and for no other purpose.

Strategies: none selected

FGI Coeff: 0

Tunnels Coeff: 0

JSON Parameters: {}

2 Paths

5 paths found. Paths are sorted by score. Reactions are sorted in appearance order for each path.

2.1 Path 1

Score: 76.25



Figure 1: Outline of path 1

2.1.1 Addition of silanes to Michael acceptors followed by oxidation

Substrates:

- 1. (z)-3-bromo-4-phenyl-3-buten-2-one
- 2. DMPSCl available at Sigma-Aldrich

Products:

1. 3-bromo-4-hydroxy-4-phenyl-butan-2-one

 $\textbf{Typical conditions:}\ 1. nBuLi. 2. CuCN. 3. electrophile. 4. H2O2$

Protections: none

 $\label{eq:Reference: 10.1021/ja058370g} \quad \text{AND} \quad \text{(Oxidation)} \quad 10.1021/jo9905672 \quad \text{or} \quad$

10.1021/ol300832f

Retrosynthesis ID: 20295

2.1.2 Nucleophilic substitution with azides

Substrates:

1. Potassium azide - available at Sigma-Aldrich

2. 3-bromo-4-hydroxy-4-phenyl-butan-2-one

Products:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Typical conditions: DMF.heat

Protections: none

Reference: 10.1021/ol049369+ and 10.1016/S0040-4039(00)61343-6 and

10.1016/j.bmcl.2005.03.055

2.1.3 Dehydration of Beta Hydroxy Carbonyl Compounds

Substrates:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Products:

1. (z)-3-azido-4-phenyl-but-3-en-2-one

Typical conditions: TsOH

Protections: none

Reference: DOI:10.1002/anie.201204977 AND 10.1021/ol0627770

Retrosynthesis ID: 7732

2.2 Path 2

Score: 84.06

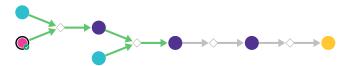


Figure 2: Outline of path 2

2.2.1 Pinacol Coupling Reaction

Substrates:

- 1. 3,4-epoxy-4-phenyl-butan-2-on
- 2. Ethanal available at Sigma-Aldrich

Products:

1. CC(O)C(C)(O)C1OC1c1ccccc1

 $\textbf{Typical conditions:} \ \, \text{Mg.NH4Cl.H2O or Mg.SmI2.TMSCl.THF.HMPA}$

Protections: none

Reference: 10.1021/jo982497p p. 3234, 3236 and 10.1021/ol0506258 p. 2366, SI

p. S12

Retrosynthesis ID: 10205

2.2.2 Ring-opening of epoxides or thiiranes with azides

Substrates:

1. hydrazoic acid

2. CC(O)C(C)(O)C1OC1c1ccccc1

Products:

1. CC(O)C(C)(O)C(N=[N+]=[N-])C(O)c1ccccc1

Typical conditions: NaN3.NH4Cl.MeOH.H2O.65 C

Protections: none

Reference: 10.1021/jm400529f p. 4361, 4367 and 10.1021/ja003713q p. 1590,

1594

Retrosynthesis ID: 858

2.2.3 Cleavage of 1,2-diols with NaIO4

Substrates:

1. CC(O)C(C)(O)C(N=[N+]=[N-])C(O)c1ccccc1

Products:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

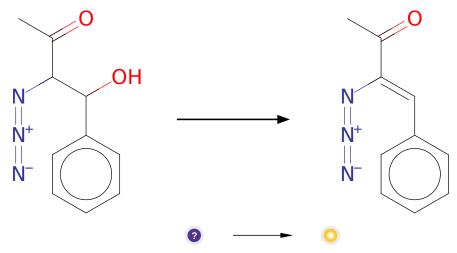
Typical conditions: NaIO4.solvent

Protections: none

Reference: 10.1039/C50B00238A and 10.1002/chem.201301371 and

10.1021/ol052106a

2.2.4 Dehydration of Beta Hydroxy Carbonyl Compounds



Substrates:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Products:

1. (z)-3-azido-4-phenyl-but-3-en-2-one

Typical conditions: TsOH

Protections: none

Reference: DOI:10.1002/anie.201204977 AND 10.1021/ol0627770

Retrosynthesis ID: 7732

2.3 Path 3

Score: 84.06

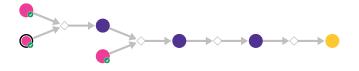


Figure 3: Outline of path 3

2.3.1 Free-radicals synthesis of benzoyl esters

Substrates:

1. 3-bromo-4-phenylbutan-2-one - available at Sigma-Aldrich

2. Luperox(r) A98 - available at Sigma-Aldrich

Products:

1. CC(=O)C(Br)C(OC(=O)c1ccccc1)c1ccccc1

Typical conditions: CuBr

Protections: none

Reference: DOI: 10.1021/jo01265a066

Retrosynthesis ID: 332

2.3.2 Nucleophilic substitution with azides

Substrates:

1. Potassium azide - available at Sigma-Aldrich

2. CC(=O)C(Br)C(OC(=O)c1ccccc1)c1ccccc1

Products:

1. CC(=O)C(N=[N+]=[N-])C(OC(=O)c1ccccc1)c1ccccc1

 ${\bf Typical\ conditions:\ DMF.} heat$

Protections: none

Reference: 10.1021/ol049369+ and 10.1016/S0040-4039(00)61343-6 and

10.1016/j.bmcl.2005.03.055

Retrosynthesis ID: 31011251

2.3.3 Hydrolysis of benzoates

Substrates:

1. CC(=O)C(N=[N+]=[N-])C(OC(=O)c1ccccc1)c1ccccc1

Products:

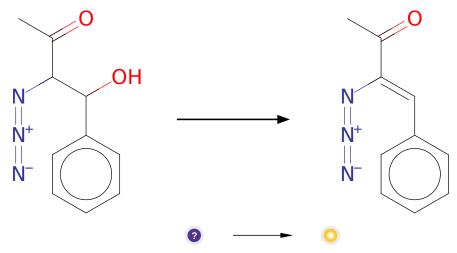
1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

 $\textbf{Typical conditions:} \ \, \text{LiOH/K2CO3/NH3.MeOH.H2O.THF}$

Protections: none

Reference: 10.1021/jm0502788 and 10.1016/j.tetlet.2008.09.165 and 10.1021/jm034098e and 10.1021/jo049277y and 10.1055/s-0033-1338657

2.3.4 Dehydration of Beta Hydroxy Carbonyl Compounds



Substrates:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Products:

1. (z)-3-azido-4-phenyl-but-3-en-2-one

Typical conditions: TsOH

Protections: none

Reference: DOI:10.1002/anie.201204977 AND 10.1021/ol0627770

Retrosynthesis ID: 7732

2.4 Path 4

Score: 90.31

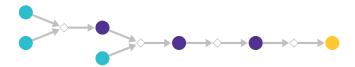


Figure 4: Outline of path 4

${\bf Substrates:}$

- 1. 2-ethoxy-[1,3]dioxolane
- 2. 3,4-epoxy-4-phenyl-butan-2-on

Products:

1. CC1(C2OC2c2cccc2)OCCO1

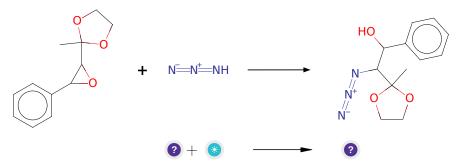
Typical conditions: indium triflate. MeOH. CH2Cl2. 20C

Protections: none

Reference: DOI: 10.1016/j.tetlet.2006.10.111 or DOI: 10.1002/cber.19620950803

Retrosynthesis ID: 9318

2.4.2 Ring-opening of epoxides or thiiranes with azides



Substrates:

- $1. \ \mathrm{CC1}(\mathrm{C2OC2c2cccc2})\mathrm{OCCO1}$
- 2. hydrazoic acid

Products:

1. CC1(C(N=[N+]=[N-])C(O)c2cccc2)OCCO1

Typical conditions: NaN3.NH4Cl.MeOH.H2O.65 $\,\mathrm{C}$

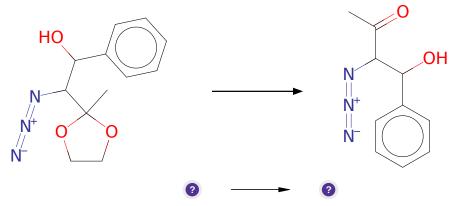
Protections: none

Reference: 10.1021/jm400529f p. 4361, 4367 and 10.1021/ja003713q p. 1590,

1594

Retrosynthesis ID: 858

2.4.3 Hydrolysis of ketals



Substrates:

1. CC1(C(N=[N+]=[N-])C(O)c2cccc2)OCCO1

Products:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Typical conditions: H2O.HCl

Protections: none

Reference: 10.1021/jo0159035 and 10.1021/jo00194a003 and

2.4.4 Dehydration of Beta Hydroxy Carbonyl Compounds

Substrates:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1

Products:

1. (z)-3-azido-4-phenyl-but-3-en-2-one

Typical conditions: TsOH

Protections: none

Reference: DOI:10.1002/anie.201204977 AND 10.1021/ol0627770

Retrosynthesis ID: 7732

2.5 Path 5

Score: 107.89



Figure 5: Outline of path 5

2.5.1 Darzens Condensation

Substrates:

1. 2-(Boc-amino)benzaldehyde - available at Sigma-Aldrich

2. brom-aceton - AstaTech

Products:

1. CC(=O)C1OC1c1ccccc1NC(=O)OC(C)(C)C

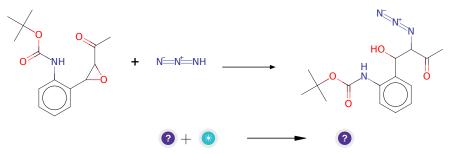
 ${\bf Typical\ conditions:}\ {\rm KOtBu.HOtBu}$

Protections: none

Reference: 10.1002/0471264180.or005.10 and 10.1021/cr50002a002

Retrosynthesis ID: 11513

2.5.2 Ring-opening of epoxides or thiiranes with azides



Substrates:

- 1. CC(=O)C1OC1c1ccccc1NC(=O)OC(C)(C)C
- 2. hydrazoic acid

Products:

1. CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1NC(=O)OC(C)(C)C

Typical conditions: NaN3.NH4Cl.MeOH.H2O.65 $\,\mathrm{C}$

Protections: none

Reference: 10.1021/jm400529f p. 4361, 4367 and 10.1021/ja003713q p. 1590,

1594

Retrosynthesis ID: 858

2.5.3 Dehydration of Beta Hydroxy Carbonyl Compounds

Substrates:

1.
$$CC(=O)C(N=[N+]=[N-])C(O)c1ccccc1NC(=O)OC(C)(C)C$$

Products:

1. CC(=O)/C(=C/c1ccccc1NC(=O)OC(C)(C)C)N=[N+]=[N-]

Typical conditions: TsOH

Protections: none

Reference: DOI:10.1002/anie.201204977 AND 10.1021/ol0627770

Retrosynthesis ID: 7732

2.5.4 Boc removal



Substrates:

1. CC(=O)/C(=C/c1ccccc1NC(=O)OC(C)(C)C)N=[N+]=[N-]

Products:

1. CC(=O)/C(=C/c1cccc1N)N=[N+]=[N-]

Typical conditions: TFA.DCM

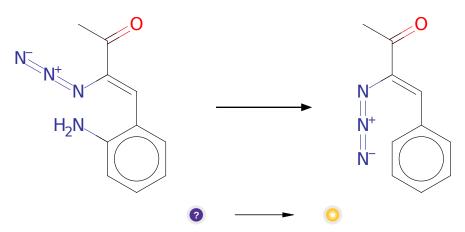
Protections: none

Reference: 10.1016/j.ejmech.2017.06.062 and 10.1016/j.bmcl.2008.02.079 and

10.1016/j.tetlet.2009.09.087 and 10.1016/j.bmcl.2015.06.039

Retrosynthesis ID: 10025813

2.5.5 Hydrodediazoniation



Substrates:

1. CC(=O)/C(=C/c1cccc1N)N=[N+]=[N-]

Products:

1. (z)-3-azido-4-phenyl-but-3-en-2-one

Typical conditions: 1) HCl.NaNO2 2) H3PO2

Protections: none

Reference: 10.1016/j.bmcl.2013.10.058 and 10.1021/jm0004906 and

10.1002/ejoc.200600030 and 10.1016/j.tet.2016.02.011